

# Sensitive F<sub>2</sub> Absorption Diagnostic

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Interim Report

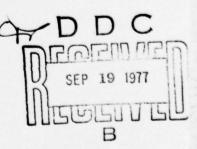
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This report whas been reviewed by the Information Office (OI) and is releasable to the National Technical Information Service (NTIS). At NTIS, it will be available to the general public, including foreign nations.

This technical report has been reviewed and is approved for publication. Publication of this report does not constitute Air Force approval of the report's findings or conclusions. It is published only for the exchange and stimulation of ideas.

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Absorption Measurement

Chemical Laser F<sub>2</sub> Measurement

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20 ABSTRACT (Continue on reverse side if necessary and identify by block number)

A sensitive  $F_2^{\eta}$  absorption diagnostic technique was developed by which a difference in absorption sensitivity of  $\Delta I/I_0 = 10^{-4}$  can be determined. This value corresponds to an  $F_2$  pressure path length product of 0.215 Torr cm at 300 K. The method was applied to an HF(DF) chemical laser flow and resulted in measured average nozzle-exit values ( $\alpha$ ) of from 0.4 to 0.5 from a totally dissociated plenum, indicating a large degree of nozzle wall recombination.

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### PREFACE

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#### I. INTRODUCTION

Uncertainties in the F-atom concentrations in the cavity flow region of cw HF and DF chemical lasers have hampered chemical efficiency calculations and plagued analytical attempts to model this type laser since its inception in 1969 [1,2]. F-atom uncertainties in the cavity region arise both as a result of uncertainties in F-atom concentrations in the plenum (resulting from temperature uncertainty and nonequilibrium chemistry effects) and uncertainties introduced by wall recombination of F atoms in the expansion nozzles [3,4]. This situation exists for both arc-heated and combustor-heated chemical lasers.

A technique was developed to measure average  $F_2$  concentrations along a line in the nozzle flows from which the average F-atom concentration could be calculated for conditions of known total  $F_2$  flow.

#### II. METHOD

In this method, simple absorption by the  $F_2$  continuum was used to determine  $F_2$  concentration. Previous work in the area of differential  $F_2$  absorption measurement was performed by Suchard and Bergerson [5]. The current method was demonstrated and applied in the determination of the average  $F_2$  concentration in the arc-heated flow of a standard 36-slit, cw, HF(DF) chemical laser MESA nozzle. A Liconix Model 301M HeCd modulatable laser operating at 325 nm was employed to probe the flow. The difference between the probe-beam and reference-beam intensities was measured with two independent silicon photovoltaic detectors and displayed on an oscilloscope for  $F_2$  in the flow and no  $F_2$  in the flow. A sensitivity of  $\Delta I/I_0 = 10^{-4}$  was measured, which corresponds to a pressure-path length product of 0.215 Torr cm at 300 K.

Figure 1 is a schematic of the  $F_2$  absorption experiment. The Liconix laser is square-wave modulated at ~20 Hz by an Interstate Electronics Model P25 pulse generator. The acousto-optic, intracavity modulation employed in this laser is essential to eliminate differential transients that are generated when mechanical choppers are employed. The pulse generator also provides an external sync signal for the Tektronix Model 545 scope, which has a Tektronix Model 1A7A 10- $\mu$ V sensitivity differential plug-in amplifier.

The modulated laser beam is passed through a sapphire prism before beam-splitting to eliminate the weak horizontally polarized beam from the

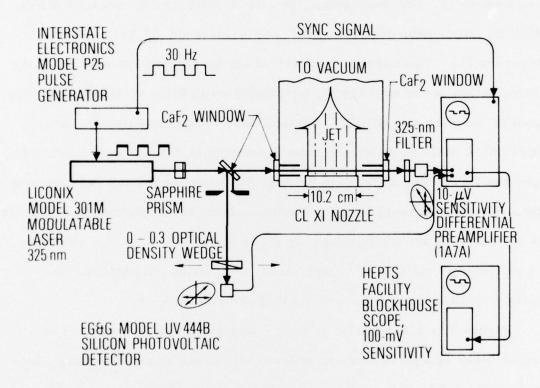


Fig. 1. Sensitive F<sub>2</sub> absorption experiment schematic

optical path, which otherwise produces differential transient noise signals because of the differences in laser turn-on and turn-off times and beamsplitter reflectivities and transmissivities, or both, relative to the vertically polarized beam. The beam splitter is a 6.25-mm-thick CaF2 flat oriented at  $\sim 45$  deg to the optical path. A thick flat (or wedge) is used as a beam splitter to eliminate one of the reflected beams to avoid noise generated from interference effects in the reference-beam detector. Orientation of the flat at  $\sim 45$  deg results in a  $\sim 15\%$  reflection of the S polarized beam from one surface of the flat. The 85% transmitted probe beam is attenuated to about this level by transmission through windows containing the absorption measurement region and (principally) through transmission through a narrow band optical filter centered at 325-nm wavelength (T ~ 16%). The reference beam also passes through a quartz, linear optical density wedge of opacity range 0 to 0.3. Translation of this optical density wedge transverse to the optical path allows refined intensity variation of the reference beam to bring the two beams, as measured on the two EG&G Model UV 444B silicon photovoltaic detectors, into a condition of zero differential signal.

The detectors were connected to the differential input jacks of the Tektronix Model 1A7A 10- $\mu$ V differential amplifier and were shunted by 1000- $\Omega$  load resistors. These load resistors maintained photovoltaic operation in the linear region of the characteristic curve. The detector radiation power sensitivity is nominally of constant value (within  $\sim 2\%$ ) over

the entire detector surface. The peak-sensitivity surface positions of the detectors were easily determined by means of the sensitive differential arrangement employed here.

It was necessary to provide the detectors with translation capability in the two directions transverse to the beams to tune the beams to the peak-sensitivity spots. This procedure was essential for achieving measurement stability because beam jitter on the sides of the peak would result in the generation of differentially uncompensated signals. However, with both detectors peaked, signal changes resulting from beam jitter were minimized to an acceptable level.

Oscilloscope presentations of the laboratory data obtained with the system are shown in Figs. 2(a), 2(b), 2(c), and 2(d). Chopping frequency for these traces is nominally 18 Hz for each case. The reference (-B) and probe (A) signals as viewed independently on the scope (they are shown here in superposition) are shown in Fig. 2(a). The signal level, corresponding to I<sub>o</sub>, is 12 mV and is displayed on either side of the zero (no light) level. Note the absence of any transient effects at the instants of chopping, either on or off. The top trace of Fig. 2(b) is the -B trace alone with a reduced amplifier frequency bandpass (0 to 1 kHz), relative to the Fig. 2(a) display (0 to 1 MHz). Simultaneous display of the balanced A - B signals results in the middle trace in Fig. 2(b). These two traces are observed at a 10-mV/cm differential gain. The bottom trace in this figure is displayed at a gain three orders of magnitude smaller than the two top

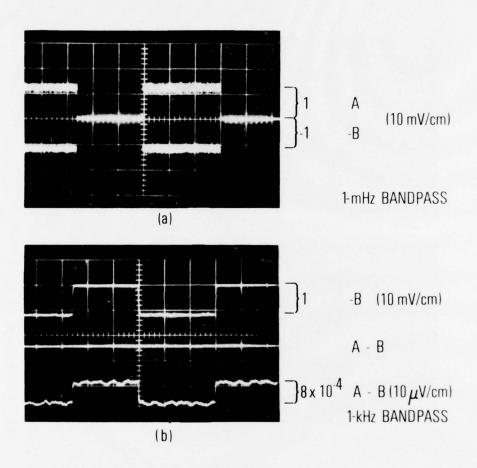


Fig. 2. F<sub>2</sub> absorption device scope traces. (a) and (b).

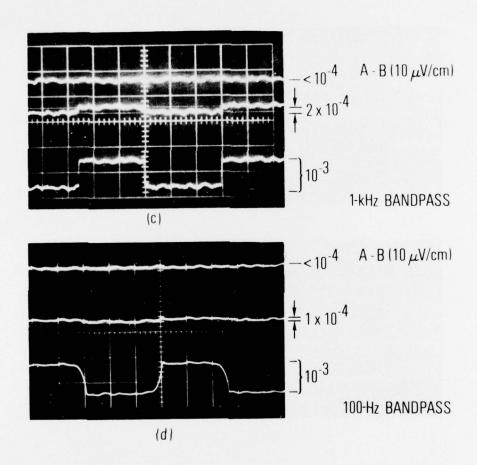


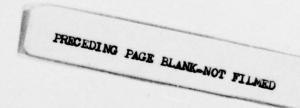
Fig. 2. F2 absorption device scope traces. (c) and (d).

traces (i.e., 10  $\mu$ V/cm), where the previously unobservable imbalance of  $\sim 9 \,\mu$ V ( $\Delta$ I/I<sub>o</sub> = 8  $\times$  10<sup>-4</sup>) is seen. Further refinements in signal presentation are shown in Figs. 2(c) and (d). Figure 2(d) was obtained with the amplifier bandpass reduced to 100 Hz. A lower limit sensitivity of 1 part in 10<sup>4</sup> is shown in the central trace.

### III. CALIBRATION

The  $F_2$  continuum absorption coefficient at 325 nm (8.70 liter/mole cm) is obtained for 298 K by interpolation of the data obtained by Steunenberg and Vogel [6]. The temperature effect on the  $F_2$  absorption coefficient for the  $F_2$  continuum has been calculated by Hofland [7] and is presented in Fig. 3 in terms of absorption coefficient versus temperature for the 325-nm wavelength HeCd laser. There is a nearly constant temperature dependence over the temperature range of interest up to  $\sim$  700 K and a maximum reduction of  $\sim$ 15% at 1500 K.

The  $F_2$  absorption diagnostic was calibrated directly in an  $F_2$  cold-flow facility.  $F_2$  density along a path length between windows was determined by introducing  $F_2$  in an  $N_2$  diluent at known partial pressures into the flowing measurement chamber while monitoring steady-state chamber pressure and temperature. A flowing system was used to ensure against  $F_2$  wall loss effects. Excellent agreement (within  $\pm 2\%$ ) was obtained over the range  $\Delta I/I_0 = 8 \times 10^{-4}$  to  $2.9 \times 10^{-2}$  between the measured absorption and the calculated absorption based upon the measured fluorine density (Fig. 4).



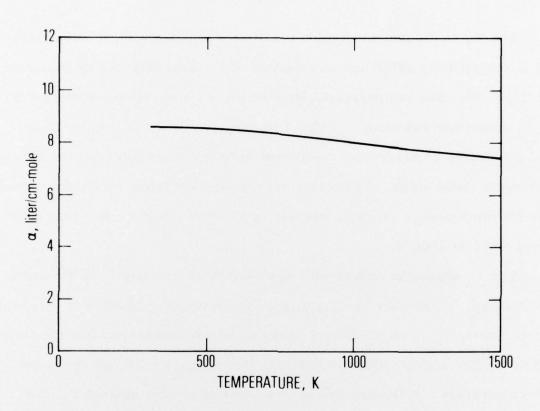


Fig. 3. Theoretical calculation of temperature effect on  $\rm F_2$  continuum absorption coefficient at 325 nm

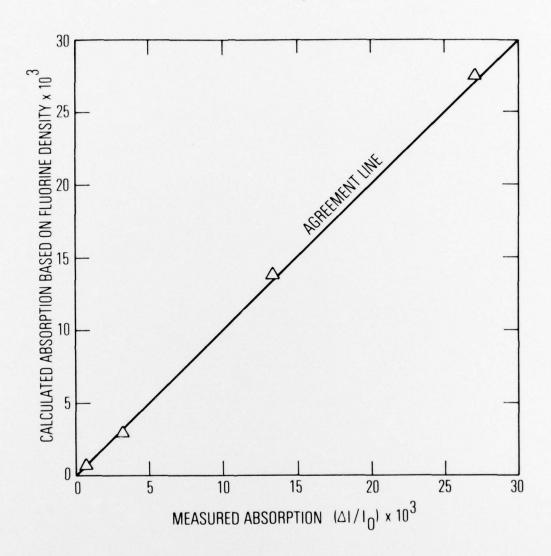


Fig. 4. F<sub>2</sub> absorption calibration in cold flow facility

#### IV. EXPERIMENTAL RESULTS

Hot-flow F<sub>2</sub> absorption measurements were made by means of the sensitive F<sub>2</sub> absorption diagnostic device in an Aerospace arc-heated, cw chemical laser facility. The probe laser beam was positioned 20 mm downstream of the nozzle exit plane along the jet centerline across the long dimension of the jet (17.8 cm). At this axial location, the jet static pressure closely approximates the more readily measurable cavity pressure. The nozzle employed was a standard 36-slit MESA nozzle [8]. CaF<sub>2</sub> windows were used for probe laser-beam transmission. The measurement was made initially for the cold flow to check the agreement with the calibration and for verification of the experimental setup.

The absorption equation for this experiment can be expressed as

$$\left(1 - \frac{\Delta I}{I_o}\right) = \exp\left[-8.70 \rho_{F_2} \text{ (mole/liter)}\right] \times 17.8 \text{ (cm)}$$
 (1)

Measurement of  $\Delta I/I_0$  allows determination of  $\rho_{\rm F}_2$ , the fluorine molar density along the probe beam in the cavity. The molar fluorine density in the cavity may also be calculated for an assumed isentropic expansion from the plenum by means of the equations

$$\rho_{F_2} = \left(\frac{\dot{n}_{F_2}}{\dot{n}_{total}}\right) \rho_c \tag{2}$$

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$$\rho_{c} = \rho_{t} \left( \frac{P_{c}}{P_{t}} \right)^{1/\gamma} \tag{3}$$

and

$$\rho_{t} = \frac{P_{t}}{RT_{t}} \tag{4}$$

where  $\rho$ , p, and T are the gas density, pressure, and temperature, respectively; subscript t refers to plenum (total) conditions; subscript c refers to cavity conditions; R is the gas constant;  $\gamma = \frac{c}{p}/\frac{c}{v}$ ; and  $\dot{n}$  is the molar flow rate.

The known mass flows of  $F_2$  and He diluent gas and measured cavity and plenum pressures allow the calculation to be made. The He diluent molar flow was 100 times the  $F_2$  flow in these tests. Hence,  $\gamma = 1.67$  was employed here. For the cold-flow tests,  $T_{+} = 300$  K.

For hot flow conditions, the plenum temperature was calculated by means of the pressure ratio method, i.e.,

$$T_{t_{Hot}} = T_{t_{Cold}} \left( \frac{P_{t_{Hot}}}{P_{t_{Cold}}} \right)^{2}$$
 (5)

for constant mass-flow conditions. A fictitious cavity molar fluorine density in a hot flow  $(\rho_{F_2})$  was then calculated with no dissociation assumed in the plenum. Division of the measured  $F_2$  density by the fictitious  $F_2$  density,

where no dissociation was assumed to have taken place, results in a convenient normalization for data presentation, i.e.,  $\rho_{F2_{measured}}/\rho_{F2_t} = 1 - \alpha$ , where  $\alpha$  is the standard dissociation level defined variously by

$$\alpha = \frac{\dot{\mathbf{m}}_{\mathbf{F}}}{\dot{\mathbf{m}}_{\mathbf{F}} + \dot{\mathbf{m}}_{\mathbf{F}_{2}}} = \frac{\dot{\mathbf{n}}_{\mathbf{F}}}{\dot{\mathbf{n}}_{\mathbf{F}} + 2\dot{\mathbf{n}}_{\mathbf{F}_{2}}} = \frac{\dot{\mathbf{n}}_{\mathbf{F}_{2}} - \dot{\mathbf{n}}_{\mathbf{F}_{2}}}{\dot{\mathbf{n}}_{\mathbf{F}_{2}_{t}}}$$

$$(6)$$

For the cold-flow case,  $\rho_{F_2} = \rho_{F_2}$ .

Data for a test series are presented in Fig. 5 in terms of  $1 - \alpha$  versus plenum temperature. Mass flows were maintained at  $\dot{m}_{He} = 4.00$  g/sec and  $\dot{m}_{F_2} = 0.445$  g/sec. The plenum pressure was 1 atm, and the cavity pressure was maintained at 10 Torr by means of downstream vernier throttling. The cold-flow measurement made at 300 K plenum temperature yielded a measured value corresponding to no dissociation, which is in agreement with expectations. As plenum temperature is increased to  $\sim 1000$  K (at 1 atm pressure), the dissociation of molecular fluorine begins and by 1500 K is complete. The dissociation curve is included in the figure to illustrate the temperature range. Because of plenum temperature uncertainties, the test points were taken over a range of temperatures to ensure that the obscuring effects of incomplete plenum dissociation were eliminated. In the temperature region from 1500 to 1900 K, the dissociation level is low, i.e.,  $\alpha < 0.5$ . In addition, the dissociation level is reduced with increased temperature, clear evidence

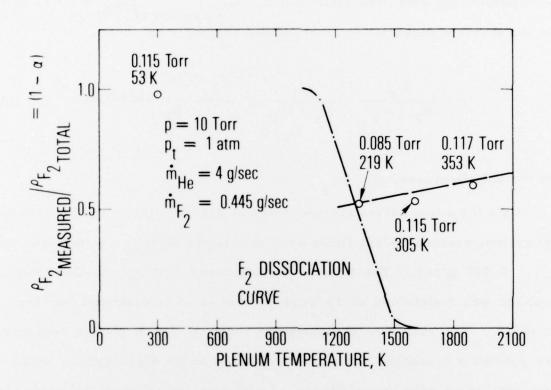


Fig. 5. F<sub>2</sub> density ratio measurement versus temperature

of strong recombination of the fluorine atoms in exhausting the nozzle. Gas-phase recombination yields only a fraction of this measured value; hence, the bulk of this recombination is expected to be the result of wall effects. The calculated cavity temperatures and F<sub>2</sub> partial pressures (average) are indicated near the room- and high-temperature experimental points for convenience.

A similar experiment was performed with  $SF_6$  as the  $F_2$  source. In this case, no cold-flow determination was possible; but hot-flow tests indicated the presence of  $F_2$  (Fig. 6). The  $SF_6$  flow indicated  $\alpha$  to be 0.79 at 1500 K with a total possible molecular fluorine flow equal to three molecules  $F_2$  per each  $SF_6$  molecule assumed for purposes of normalization. This low value is certainly the result of incomplete plenum dissociation of the  $SF_6$ . At a higher temperature, 2100 K, the measured  $\alpha$  is  $\sim$ 0.45, more nearly consistent with the  $F_2$  flow measurements. Determination of F-atom concentration from this  $SF_6$  measurement is, of course, much less straightforward than from the  $F_2$  measurements.

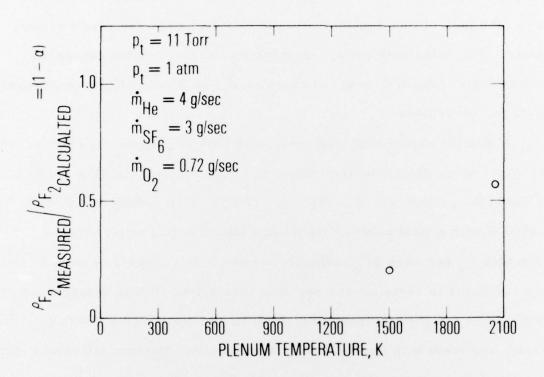


Fig. 6.  $F_2$  absorption measurements in  $SF_6$  flow

### V. CONCLUDING REMARKS

A technique was developed to measure low-level  $F_2$  concentrations by means of a difference absorption measurement with sensitivity  $\Delta I/I_0 = 10^{-4}$ , corresponding to a  $F_2$ -pressure path length product of 0.215 Torr cm at 300 K. The diagnostic was applied to a hot-flow chemical laser and indicates that a rather high recombination in the nozzle flows,  $\alpha = 0.4$  to 0.5, exists. Wall recombination in this chemical-laser nozzle may have had a dominant influence in determining F-atom concentrations in all HF (DF) chemical lasers in which this nozzle is used.

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